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(54) POLYPROPYLENE RESIN COMPOSITION**(57) Abstract:**

PROBLEM TO BE SOLVED: To obtain a polypropylene resin composition having high MFR, high gloss and excellent scratch resistance and giving a molded article having stable shape-retainability and high tapping easiness.

SOLUTION: This polypropylene resin composition has an MFR of 35g/10min and a CaCO_3 dispersion parameter of 24.5 and is composed of (A) 40-80wt.% of a polypropylene resin having an MFR of 130-1,000g/10min and an isotactic pentad fraction of

0.980, (B) 50-10wt.% of a copolymer component containing ethylene and an α -olefin units and (C) 3-35wt.% of CaCO_3 having an average particle diameter of $21.5\mu\text{m}$.

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